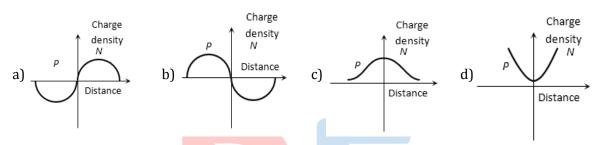


Class: XIIth Subject: PHYSICS

Date: DPP No.: 3

Topic:-.semiconductor electronics: materials, devies and simple circuits

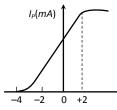
1. The curve between charge density and distance near P-N junction will be



- 2. The crystal structure can be studied by using
 - a) UV raus
- b) X-rays
- c) IR radiation
- d) Microwaves
- 3. The plate resistance of a triode is $2.5 \times 10^4 \Omega$ and mutual conductance is 2×10^{-3} mho. What will be the value of amplification factor
 - a) 50

- b) 1.25×10^7
- c) 75

- d) 2.25×10^7
- 4. The mutual characteristic curves of a triode are as shown in figure. The cut off voltage for the triode is



a) 0 *V*

b) 2 V

- c) -4V
- d)6 V
- 5. The voltage gain of an amplifier with 9% negative feedback is 10. The voltage gain without feedback will be
 - a) 1.25
- b) 100
- c) 90

- d) 10
- 6. Although carbon, silicon and germanium have same lattice structure and four valence electrons each, their band structure leads to the energy gaps as
 - a) $E_g(Si) < E_g(Ge) < E_g(C)$

 $b) E_g(Si) > E_g(Ge) < E_g(C)$

c) $E_g(Si) < E_g(Ge) > E_g(C)$

- d) $E_g(Si) > E_g(Ge) > E_g(C)$
- 7. Barrier potential of a *p-n* junction diode does not depend on
 - a) Forward bias
- b) Doping density
- c) Diode design
- d) Temperature
- 8. The nature of binding for a crystal with alternate and evenly spaced positive and negative ions

is

- a) Covalent
- b) Metallic
- c) Dipolar
- d) Ionic
- 9. The binary number 10111 is equivalent to the decimal number
 - a) 19

b)31

c) 23

- d)22
- 10. C and Si both have same lattice structure, having 4 bonding electrons in each. However, C is insulator where as Si is intrinsic semiconductor. This is because
 - a) In case of C the valance band is not completely filled at absolute zero temperature
 - b) In case of C the conduction band is partly filled even at absolute zero temperature
 - The four bonding electrons in the case of C lie in the second orbit, whereas in the case of Si they lie in the third
 - The four bonding electrons in the case of C lie in the third orbit, whereas for Si they lie in the fourth orbit
- 11. The work function of oxide coated tungsten metal will be
 - a) 0.5 eV
- b) 1.0 eV
- c) 2.6 eV
- d)4.5 eV

- 12. A logic gate is an electronic circuit which
 - a) Makes logic decisions

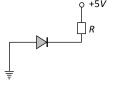
b) Allows electrons flow only in one direction

c) Works binary algebra

- d) Alternates between 0 and 1 values
- 13. Consider the junction diode is ideal. The value of current in the figure is

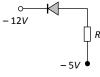
$$+4V$$
 $p-n$ $300 \Omega + 1V$

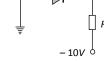
- a) Zero
- b) 10^{-2} A
- c) 10^{-1} A
- d) 10^{-3} A
- 14. A crystal has bcc structure and its lattice constant is 3.6 Å. What is the atomic radius?
 - a) 3 6 Å
- b) 1.8 Å
- c) 1.27 Å
- d) 1.567 Å
- 15. In the given figure, which of the diodes are forward biased











- a) 1, 2, 3
- b) 2, 4, 5
- c) 1, 3, 4
- d) 2, 3, 4
- 16. In space charge limited region, the plate current in a diode is 10 *mA* for plate voltage 150 *V*. If the plate voltage is increased to 600 *V*, then the plate current will be
 - a) 10 mA
- b) 40 mA
- c) 80 mA
- d) 160 mA
- 17. If D_e , D_b and D_c are the doping levels of emitter, base and collector respectively of a transistor,

then

- a) $D_e = D_b = D_c$ b) $D_e < D_b = D_c$ c) $D_e > D_b > D_c$ d) $D_e > D_c > D_b$

- 18. On applying a potential of -1 *volt* at the grid of a triode, the following relation between plate voltage V_p (*volt*) and plate current I_p (in mA) is found $I_p = 0.125 V_p - 7.5$. If on applying -3 *volt* potential at grid and 300 *V* potential at plate, the plate current is found to be 5mA, then amplification factor of the triode is
 - a) 100
- b)50

c) 30

- d) 20
- 19. A transistor has a base current of 1 mA and emitter current 90 mA. The collector current will
 - a) 90 mA
- b) 1 mA
- c) 89 mA
- d)91 mA
- 20. Suitable impurities are added to a semiconductor depending on its use. This is done to
 - a) Increase its life

- b) Enable it to withstand high voltage
- c) Increase its electrical conductivity
- d) Increase its electrical resistivity

